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IN THIS ISSUE

Fulta - vi-1
Editorial
Using Guard Columns and
Retention Gaps in GC (Part 1)
Environmental Fast, Accurate Semivolatiles Analysis! 3
Chemical/Petrochemical
Complete Resolution of Benzene from
Ethanol in Spark Ignition Fuels 6
Foods, Flavors & Fragrances
Rapid Characterization of Garlic Volatiles
No Sample Prep Required!
Clinical/Forensics
Simplify and Speed Up
Opiates Analysis
Pharmaceutical
Easy Transfer of HPLC
Methods to UHPLC
Industial Hygeine
Complete Resolution of 13 Carbonyls
as DNPH Derivatives
HPLC Accessories
Capillary Stainless Steel
Tubing Assemblies
Restek Performance Coatings
Sulfinert® Treated Systems Preserve ppb
Levels of Active Sulfur Compounds 14
Air Monitoring
Performance Testing VOC Audit
Sample for Air Toxics
Tech Tip
Affected by the Helium Shortage? 17
Warm Up Before You Run 20
GC Accessories
Parker Balston® Hydrogen Generators 18
Dual Vespel® Ring Inlet Seals
Erratum The heading of Figure 1 on page 8 of the 2007.03 issue of the Restek Advantage incorrectly describes the column internal diameter as 0.18mm. The correct internal diameter is 0.32mm.
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Using Guard Columns and Retention Gaps in GC (Part 1)

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Guard columns and retention gaps are used widely in gas chromatography (GC). Many users have difficulty understanding the difference between these two products, even though there is a significant difference in application. Retention gaps mainly are used for focusing the sample components when introducing a large (liquid) sample directly onto the column. Guard columns are used to protect the analytical column from contamination.

When using a retention gap system, the retention gap will also act as a guard column, but its primary function is to create a focusing effect.

Guard columns and retention gaps both must be coupled to the analytical column, and this connection introduces a potential point of risk. A new approach is to integrate the retention gap directly into the analytical column. By applying a "segment" coating technology, the stationary phase can be deposited in a certain part of the column allowing a deactivated section at the beginning. Column coupling is not required, and maintenance is greatly simplified. In Part 1 of this article, we will explore retention gaps and build a foundation for a comparison to guard columns. In Part 2, we will review guard columns and discuss the new segment coating technology.

Use of retention gaps

In today's laboratory, GC methods must be simple, fast, and low detection limits are required. Besides that, sufficient precision must also be obtained. It all starts by introducing the sample in the smallest possible injection band and making the band migrate through the capillary with minimal loss of the target components. With on-column injection, a liquid sample is directly introduced into the capillary column as a liquid while the capillary column is kept at a temperature 10-15°C below the boiling point of the solvent. During this process, the sample components are spread in an unreproducible way over the first 20-100cm of capillary while the solvent is evaporating. Parameters like injection speed, carrier gas flow, temperature of solvent and column, type of solvent and pressure all will affect the injection band width. Additionally, when nonbonded stationary phases are used, the direct contact with liquids will result in a distortion of the stationary phase film and very short column lifetime. The majority of today's stationary phases, like the Rtx® and Rxi® phases, are immobilized by cross- and surface bonding techniques.

For proper application of the on-column injection technique, the use of retention gaps is essential.^{1,2} The retention gap consists of a 1-3m length of deactivated capillary that is positioned in front of the analytical column. All the processes described will still take place, but now the components are distributed over the retention gap. When the oven temperature is

Continued on page 23.

